Notice of References Cited Application/Control No. | Applicant(s)/Patent Under Reexamination | WEILLER ET AL. | Examiner | Art Unit | Page 1 of 1

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	Α	US-2003/0217928	11-2003	Lin et al.	205/109
*	В	US-2003/0137083	07-2003	Ko et al.	264/449
*	С	US-5,130,009	07-1992	Marsoner et al.	204/403.11
*	D	US-4,267,506	05-1981	Shiell, Thomas J.	324/761
	Ε	US-			
	F	US-			
	G	US-			
	Ξ	US-			
	-	US-			
	J	US-			
	К	US-			
	L	US-			
	М	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification	
	N						
	0						
	Р						
	Q				17 - 17 - 1 - 1 - 1 - 1 - 1 - 1 - 1 - 1		
	R						
	S						
	Т				71.2		

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)			
	U	Briseno et al, Polymer Preprints 8-2003, 44(2), p. 140.			
	٧	Liu et al, Chemistry A European Journal, 2-2003, 9 (3), pp. 604-611			
	w	Pinto et al, Applied Physics Letters, 83(20), 11-2003, pp. 4244-4246.			
	x	Yun et al, Proceedings of SPIE Vol. 5220 Nanofabrication Technologies, 8-2003, pp. 37-45.			

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).) Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.